11- 2-04'; 5:17PM; :19496600809 # 8/ 16

Application No.: 10/712,236 Docket No.: JCLA11795

In The Specification:

Please amend paragraph [0033] as follows:

[0033] Note that the second conductive type doped region 210 of each diode 203

is coupled to the second conductive type doped region 206 and the first conductive type doped

region 208 of the following diode 203. With this setup, the emitter (the first conductive type

doped region 208) and the base (the second conductive type doped region 206) of since, in the

same diode 203, the second conductive type doped region 206 is voltage equivalent to the first

conductive type doped region 208, a parasitic bipolar junction transistor 216, constructed by the

emitter (the first conductive type doped region 208), the collector (the substrate 200) and the base

(the second conductive type doped region 206), within the substrate 200 are non-conductive is

turned off. Hence, conduction between the emitter (the first conductive type doped region 208)

and the collector (the substrate 200) of the parasitic bipolar junction transistor 216 is also

prevented thereby resolving the current leak problem of conventional diodes.

Please amend paragraph [0042] as follows:

[0042] Note that the diode structure according to this invention still includes a

parasitic bipolar junction transistor 316 within the substrate 300. However, the base (the second

conductive type doped region 306) and the emitter (the first conductive type doped region 308) of

the parasitic bipolar junction transistor 316 do not conduct because the base is at a voltage higher

than (or equal to) the emitter the base (the second conductive type doped region 306) is at a

Page 7 of 15

BEST AVAILABLE COPY

11- 2-04'; 5:17PM; ;19496600809 # 9/ 16

Docket No.: JCLA11795

Application No.: 10/712,236

voltage higher than (or equal to) the emitter (the first conductive type doped region 308). Therefore, the parasitic bipolar junction transistor 316 possesses the base, the collector and the emitter is turned off. Hence, conduction between the emitter (the first conductive type doped region 308) and the collector (the substrate 300) of the parasitic bipolar junction transistor 316 is also prevented thereby resolving the current leak problem of conventional diodes.

This Page is Inserted by IFW Indexing and Scanning Operations and is not part of the Official Record

BEST AVAILABLE IMAGES

Defective images within this document are accurate representations of the original documents submitted by the applicant.

Defects in the images include but are not limited to the items checked:	
☐ BLACK BORDERS	
☐ IMAGE CUT OFF AT TOP, BOTTOM OR SIDES	
☐ FADED TEXT OR DRAWING	
☐ BLURRED OR ILLEGIBLE TEXT OR DRAWING	
☐ SKEWED/SLANTED IMAGES	
COLOR OR BLACK AND WHITE PHOTOGRAPHS	
GRAY SCALE DOCUMENTS	
☐ LINES OR MARKS ON ORIGINAL DOCUMENT	
☐ REFERENCE(S) OR EXHIBIT(S) SUBMITTED ARE POOR QUALITY	
Потика.	

IMAGES ARE BEST AVAILABLE COPY.

As rescanning these documents will not correct the image problems checked, please do not report these problems to the IFW Image Problem Mailbox.